WEST Search History

Hide Items Restore Clear Cancel

DATE: Thursday, April 27, 2006

Hide?	Set Name	Query	<u>Hit</u> Count
	DB=USPT; $PLUR=YES$; $OP=ADJ$		
<u> </u>	L29	6494220.pn. or 6516815.pn.	2
	DB =	PGPB,USPT,USOC; PLUR=YES; OP=ADJ	
	L28	L27 and 115	61
	L27	134/26,27,28,29,36,22.1,22.18,902;438/905,906.ccls.	7696
	L26	121 same (wafer or object or substrate or workpiece or semiconductor)	4
	DB =	EPAB,JPAB,DWPI; PLUR=YES; OP=ADJ	
	L25	090290199	0
Γ.	L24	90290199	0
Е	L23	290199	8
	L22	9290199	0
	DB =	PGPB,USPT,USOC; PLUR=YES; OP=ADJ	
Ţ.	L21	((clean\$3 or wash\$3 or rins\$3) adj (support\$3 or chuck\$3 or piedestal or hold\$3)) with (cup or chamber or reservoir) with (liquid or wet or solution or solvent)	46
	DB = 0	EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ	
Γ	L20	((clean\$3 or wash\$3 or rins\$3) adj (support\$3 or chuck\$3 or piedestal or hold\$3)) with (cup or chamber or reservoir) with (liquid or wet or solution or solvent)	11
Ľ	L19	((clean\$3 or wash\$3) adj (support\$3 or chuck\$3 or piedestal or hold\$3)) with (cup or chamber or reservoir) with (liquid or wet or solution or solvent) with (wafer or object or substrate or workpiece)	2
Γ	L18	((clean\$3 or wash\$3) adj5 (support\$3 or chuck\$3 or piedestal or hold\$3)) with (cup or chamber or reservoir) with (liquid or wet or solution or solvent) with (wafer or object or substrate or workpiece) with rins\$3	2
С	L17	((clean\$3 or wash\$3 or rins\$3) adj5 (support\$3 or chuck\$3 or piedestal or hold\$3)) with (cup or chamber or reservoir) with (liquid or wet or solution or solvent) with (wafer or object or substrate or workpiece)	67
	DB = 0	PGPB,USPT,USOC; PLUR=YES; OP=ADJ	
	L16	L15 and 19	53
Ľ	L15	((clean\$3 or wash\$3 or rins\$3) adj5 (support\$3 or chuck\$3 or piedestal or hold\$3)) with (cup or chamber or reservoir) with (liquid or wet or solution or solvent) with (wafer or object or substrate or workpiece)	146
	L14	L13 and 19	73
Γ.	L13	((clean\$3 or wash\$3) adj5 (support\$3 or chuck\$3 or piedestal or hold\$3)) with	740

		(cup or chamber or reservoir) with (liquid or wet or solution or solvent)	
	L12	L11 and 19	164
Γ	L11	((clean\$3 or wash\$3) adj5 (support\$3 or chuck\$3 or piedestal or hold\$3)) with (cup or chamber or reservoir)	3859
	DB =	PGPB,USPT,USOC,EPAB,JPAB,DWPI; PLUR=YES; OP=ADJ	
Γ	L10	L9 and 18	726
\Box	L9	134/22.1,22.18,902.ccls.	4186
Γ.	L8	(clean\$3 or wash\$3) adj5 (support\$3 or chuck\$3 or piedestal or hold\$3)	74026
<u> </u>	L7	L6 and ((clean\$3 or wash\$3) same cup same (support\$3 or chuck\$3 or piedestal or hold\$3) same rins\$3)	4
Γ.	L6	L5 or 14 or 13 or 12 or 11	24073
Γ	L5	ariga-yoshikazu\$.in.	6
	L4	miyashita-mitsuo\$.in.	16
	L3	nishioka-yukiko\$.in.	47
Γ	L2	yonekura-ryosuke\$.in.	5
Γ.	L1	(ebara).as.	24048

END OF SEARCH HISTORY